Supporting Information

Long conducting polymer nanonecklaces with a 'beads-on-astring' morphology: DNA nanotubes-template synthesis and their electrical property

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Fig. S1 Schematic of the synthesis of long conducting PMTP nanonecklaces based on selfassembled DNA nanotubes

Experimental Section

Formation of self-assembled DNA nanotubes by 2-day slow annealing

The sequence of 52-nucleotide ssDNA with 4 palindromic segments of 10, 16, 16 and 10 bases long (5'- CCA AGC TTG GAC TTC AGG CCT GAA GTG GTC ATT CGA ATG ACC TGA GCG CTC A -3') were designed by a computer program "SEQUIN".¹ All oligonucleotides were purchased from IDT, Inc. and purified by 20% denaturing polyacrylamide gel electrophoresis (PAGE); bands were cut out of gels and eluted in a solution containing ammonium acetate (500 mM), magnesium acetate (10 mM), and ethylenediamine tetraacetic acid (EDTA; 1 mM). The

self-assembled DNA nanotubes were formed following the modified procedure published in previous paper.^[17] Briefly, 20 μ L ssDNA of 5 μ M was prepared by dissolving the purified oligonucleotides (52 nt) in 1×TAE/Mg²⁺ buffer (40 mM Tris base, 20 mM acetic acid, 2 mM EDTA and 12.5 mM magnesium acetate). Then slowly cool down solution from 95 to 4 °C for 48 h.

Template-synthesis of PMTP/DNA nanonecklaces at surface-immobilized DNA nanotubes

1. On mica by blow drying

5 μ L of self-assembled DNA nanotubes in 1×TAE/Mg²⁺ buffer was deposited onto the freshly cleaved mica and blown dry with compressed air. The surface was rinsed with DI water and blown dry. Then 50 μ L of 0.1 M FeCl₃ aqueous solution was added onto the mica and left to incubate for 10 min within closed petri dish, followed by 4 cycles of DI water washing and compressed air blow drying. To initiate efficient polymerization reaction, the residual water should be removed thoroughly and oxygen-free reaction environment need to be kept. Therefore, the mica with FeCl₃-impregnated DNA nanotubes was heated at 37 °C for 30 min to remove the residual water, followed by blow dry with the compressed nitrogen. Subsequently, 50 μ L of *3*- methylthiophene monomer was added and allowed to incubate with FeCl₃-impregnated DNA for 1 min. After removing the *3*-methylthiophene monomer by compressed air blowing, the surface was rinsed thoroughly with methanol to further clean un-reacted monomer, dried with compressed air and characterized with AFM.

2. On UV ozone-modified silicon wafer with the gold source-drain electrodes by natural drying

For the electrical measurement, PMTP/DNA nanonecklaced structures were also prepared on silicon wafer with the gold source-drain electrodes. The embedded gold electrodes were formed by photolithography on a Si wafer with 300-nm SiO₂ surface layer. The silicon wafer was first cleaned with hot piranha solution $(H_2SO_4 (98\%)/H_2O_2 (30\%) = 7/3 (v/v))$, followed by sonication in DI water and acetone for 6 min respectively. Then the silicon wafer was modified to be hydrophilic by the exposure to UV-ozone for 1 h. To form PMTP/DNA nanonecklaces on the silicon wafer, 20 µL of self-assembled DNA nanotubes in 1×TAE/Mg²⁺ buffer was deposited and left to evaporate till complete drying. Then 100 µL of 0.1 M FeCl₃ aqueous solution was added onto the silicon wafer and allowed to incubate for 10 min within closed petri dish, followed by 4 cycles of DI water washing and compressed air blow drying. Moreover, the silicon wafer with FeCl₃-impregnated DNA nanotubes was heated at 37 °C for 30 min to remove the residual water, followed by blow dry with the compressed nitrogen. Subsequently, 100 µL of 3methylthiophene monomer was added and allowed to incubate with FeCl₃-impregnated DNA for 1 min. After removing the 3-methylthiophene monomer by compressed air blowing, the surface was rinsed thoroughly with methanol to further clean un-reacted monomer, dried with compressed air and characterized with AFM and Keithley 4200 Semiconductor Characterization System.

3. On carbon-coated copper TEM grids

The carbon-coated copper TEM grid was modified to be hydrophilic by the exposure to UVozone for 30 min. To form PMTP/DNA nanonecklaces on the TEM grid, 10 μ L of selfassembled DNA nanotubes in 1×TAE/Mg²⁺ buffer was deposited on the grid held by self close clamping tweezer and left to evaporate till complete drying. Then 10 μ L of 0.1 M FeCl₃ aqueous solution was added onto the copper TEM grid and allowed to incubate for 10 min within closed petri dish, followed by 4 cycles of DI water washing and compressed air blow drying. Moreover, the TEM grid with FeCl₃-impregnated DNA nanotubes was heated at 37 °C for 30 min to remove the residual water, followed by blow dry with the compressed nitrogen. Subsequently, 10 µL of *3*-methylthiophene monomer was added and allowed to incubate with FeCl₃-impregnated DNA for 1 min. After removing the *3*-methylthiophene monomer by compressed air blowing, the surface was rinsed thoroughly with methanol to further clean un-reacted monomer, dried with compressed air, and characterized by TEM/EDX.

AFM imaging

A MultiMode 8 AFM (Bruker) was used to image the samples under ScanAsyst-Air mode, using a ScanAsyst-air nanoprobe (Bruker).

TEM/EDX characterization

Dark-field TEM imaging and EDX element analysis were conducted on a Tecnai T20 field emission transmission electron microscope with accelerating voltage of 200 kV.

Two terminal current-voltage characterization

Two-terminal current-voltage measurements were performed using Signatone Triaxial Probe Station and Keithley 4200 Semiconductor Characterization System. The current was measured for applied voltages from -10 to 10 V in steps of 0.05 V. All of the electrical measurements were carried out in air at room temperature.

Reference

1. N. C. Seeman, J. Biomol. Struct. Dyn. 1990, 8, 573.